The Frederic Stanley Kipping Award in Silicon Chemistry

Paul Martin Zelisko

Published online: 16 September 2010
© Springer Science+Business Media B.V. 2010

In 1960 the Dow Corning Corporation established an award, to be administered by the American Chemical Society (ACS), to recognize the achievement of individuals in the field of silicon chemistry. The award was named the Frederic Stanley Kipping Award in Silicon Chemistry to commemorate the contributions of one of the true pioneers in this field. Since 1976 the Kipping Award has been presented on a biennial basis to an individual who has made distinguished contributions to the field of silicon chemistry or organometallic chemistry of the Group IV elements in the 10 years preceding the nomination, regardless of age or nationality.

Recipients of the Kipping Award

2010 Yitzhak Apeloig
2008 T. Don Tilley
2006 Akira Sekiguchi
2004 James E. Mark
2002 Kohei Tamao
2000 Peter Jutzi
1998 Joseph B. Lambert
1996 Wataru Ando
1994 Robin Walsh

1992 Nils Wiberg
1990 John L. Speier, Jr.
1988 Raymond Calas
1986 Peter P. Gaspar
1984 Robert J. P. Corriu
1982 Thomas J. Barton
1980 E. A. V. Ebsworth
1978 Hideki Sakurai
1976 Michael F. Lappert
1975 Hans Bock
1974 Hubert Schmidbaur
1973 Adrian G. Brook
1972 Dietmar Seyferth
1971 Alan G. MacDiarmid
1970 Robert West
1969 Robert A. Benkeser
1968 Ulrich Wannagat
1967 Makoto Kumada
1966 Gerhard Fritz
1965 Eugene G. Rochow
1964 Colin Eaborn
1963 Leo H. Sommer
1962 Henry Gilman

P. M. Zelisko (✉)
Department of Chemistry and Centre for Biotechnology,
Brock University,
500 Glenridge Avenue,
St. Catharines, Ontario L2S 3A1, Canada
e-mail: pzelisko@brocku.ca